

# Technology Paper Highlights

**224** submissions, highest since 2006, with acceptance rate **38%**

**Top contributed papers** in core technology and SOC: first **10 nm FinFET** platform with  $0.053 \mu\text{m}^2$  SRAM (Samsung) and **14 nm FDSOI** platform (ST); emerging device technology on Si substrates in **SiGe FinFET** (IBM), **III-V FinFET** (imec) and strained **SiGe nanowire FET** (CEA-LETI); emerging nonvolatile logic in **Cu atom switch** (LEAP) and memory in **all-printing paper memory** (NTU); **design/technology co-optimization** for 20 nm SOC (Qualcomm); functional diversification in first **curved image sensor** (Sony) and **Si photonics** for future interconnect (Micron)

**3 Late News** papers pushing device technology envelope: record performances in 25 nm  $L_g$  III-V MOSFET (UCSB); 2D channel MoS<sub>2</sub> FET (Purdue U.); stacked high- $\mu$  channel CMOS (AIST)

**Invited talks** in focus sessions (**Technology** and **Joint**) to provide critical insights:

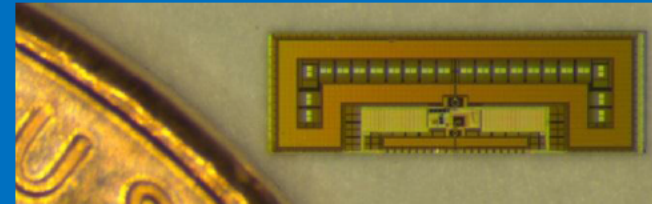
- Embedded Non-volatile Memory**: opportunities for NVM in advanced technology nodes -- One-Time-Program memory for HKMG and FinFET (eMemory); STT-MRAM for mobile systems with extremely power efficient operation (Qualcomm)
- Interconnect**: scaling challenges -- scaling at the local interconnect and contact to impact on performance (PSU); process scaling in an increasingly interconnect dominated environment (Intel); interconnect scaling to the 5 nm node (Tohoku U.)
- 3D Systems and Packaging** (joint): redundancy implementation at the microbump level for yield and reliability (Xilinx); challenges in advanced TSV technology (SK Hynix)
- Design co-optimization** (joint): Internet of Things -- IoT driven ultra low power devices and design practices (U. Michigan); Silicon-on-Thin-Buried-Oxide to enable low power devices for IoT (LEAP)

# Circuits Papers

- **New record of Submissions**
- **Paper Highlights**
  - **SOC Circuits and Processors**  
Security (Intel 22nm, Kobe), LPLV- $\mu$ P (MIT)
  - **Memory Innovation**  
1GHz SRAM (Renesas 28nm),  
LP STT-MRAM (Toshiba), SSD-Flash (U Chuo)
  - **Wireless Sensors & Medical Electronics**  
Pad-less 24/60 GHz Radio (Berkeley), Battery  
Supervision (U Mich), ECG-Shirt (U Wash.)
  - **Data Converter Circuits**  
200 MS/s SAR ADC (Renesas 28nm)  
11 GS/s DAC (U Twente 28nm FD-SOI)
  - **Frequency Generation & Clock Circuits**  
TDC (Samsung 28nm), Dig. PLL (TSMC 28nm)
  - **Wireline Receivers and Transmitters**  
e.g. 40 Gb/s Rambus 28nm, Broadcom 40nm

## Fastest growing category

Biomedical, Sensor & Display Circuits  
+70% vs. 2012



24/60 GHz passive radio system (UCB / SU)

## Circuits in Advanced Nodes

- |                 |                               |
|-----------------|-------------------------------|
| • 14nm Intel    | Clock generator               |
| • 16nm TSMC     | Temp. sensor                  |
| • 20nm ARM      | eSRAM                         |
| • 20nm Fujitsu  | Transceiver, RX               |
| • 20nm MediaTek | DAC, $\Delta\Sigma$ modulator |
| • 22nm Intel    | eDRAM, AES,<br>VDD-Regulator  |